Erratum: Multiple Bifurcation Types and the Linear Dynamics of Ion Sputtered Surfaces
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The equation of the line in Fig. 3(c) of our Letter should be $5.7 \times 10^{-5}\ (19° - \theta)$ and not $5.7 \times 10^{-7}\ (19° - \theta)$. No changes need to be made to the text, and this correction does not affect the conclusions of the work.
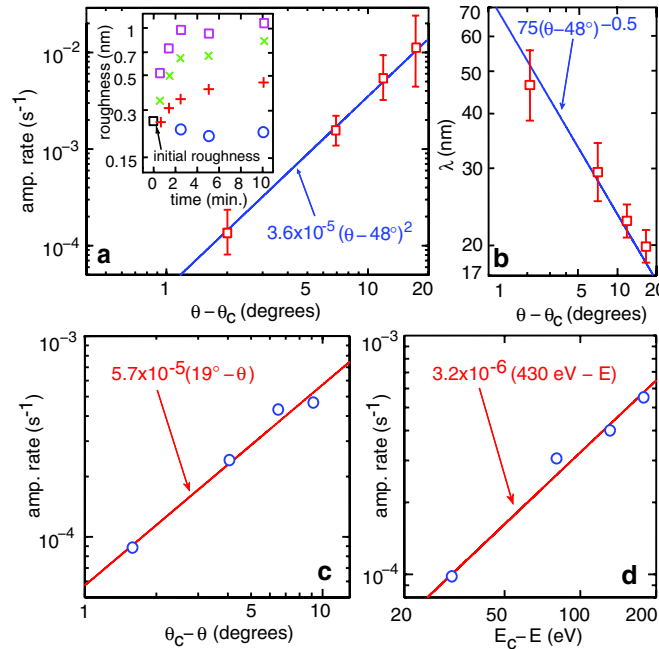

FIG. 3 (color online).　Behavior near bifurcation points for (a),(b) high-θ and (c),(d) low-θ bifurcations. (a) Amplification rate versus misorientation for high-θ bifurcation. Inset: Pattern amplitude (reckoned as rms surface roughness) versus time. Squares: 65°; ×: 60°; +: 55°; circles: 50°. (b) Wavelength versus misorientation for high-θ bifurcation. (c) Amplification rate versus misorientation for low-θ bifurcation. (d) Amplification rate versus E at $\theta = 10°$. In (a)–(c), $E = 250$ eV.